AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

- 1. (original): Method for coating the surface of a metal material having a crystallographic structure, according to which the material is first coated with a layer of a metal or a metal alloy having a melting point equal to T_f and a thickness less than or equal to $2.5\mu m$, characterised in that:
- the first coating is subjected to thermal processing using a rapid heating means in order to bring the surface of the first coating to a temperature of between $0.8T_{\rm f}$ and $T_{\rm f}$;
- a second coating is deposited from a metal or a metal alloy having a thickness less than or equal to $1\mu m. \,$
- 2. (original): Method according to claim 1, characterised in that the first and second coatings have melting points less than or equal to 700°C.
- 3. (currently amended): Method according to claim 1-or 2, characterised in that the first and second coatings are constituted by the same material.
- 4. (currently amended): Method according to any one of claims 1 to 3claim 1, characterised in that a transparent mineral film is then deposited on the second coating.
- 5. (currently amended): Method according to any one of claims 1 to 4claim 1, characterised in that the metal material to be coated is a carbon steel.

- 6. (currently amended): Method according to any one of claims 1 to 4claim 1, characterised in that the metal material to be coated is a stainless steel.
- 7. (currently amended): Method according to any one of claims 1 to 4claim 1, characterised in that the metal material to be coated is aluminium or one of the alloys thereof.
- 8. (currently amended): Method according to any one of claims 1 to 7 claim 1, characterised in that the first coating is produced by means of electrodeposition.
- 9. (currently amended): Method according to any one of claims 1 to 7claim 1, characterised in that the first coating is produced by a physical vapour deposition method.
- 10. (currently amended): Method according to any one of claims 1 to 9claim 1, characterised in that the means for rapid heating is an infra-red heating device.
- 11. (currently amended): Method according to any one of claims 1 to 9claim 1, characterised in that the means for rapid heating is an induction heating device.
- 12. (currently amended): Method according to any one of claims 1 to 9claim 1, characterised in that the means for rapid heating is a device for discharge with plasma with a non-reactive gas.
- 13. (currently amended): Method according to any one of claims 1 to 9claim 1, characterised in that the means for rapid heating is a device for ion bombardment with a non-reactive gas.
- 14. (currently amended): Method according to any one of claims 1 to 13claim 1, characterised in that the second coating is produced by means of electrodeposition.

- 15. (currently amended): Method according to any one of claims 1 to 13claim 1, characterised in that the second coating is produced by means of a physical vapour deposition method.
- 16. (currently amended): Method according to any one of claims 4 to 15claim 4, characterised in that the transparent mineral film is deposited by means of a reactive plasma assisted chemical vapour deposition method.
- 17. (currently amended): Method according to any one of claims 1 to 16 claim 1, characterised in that the first and/or second coating(s) is/are constituted by tin.
- 18. (currently amended): Method according to any one of claims 1 to 17claim 1, characterised in that the first and/or second coating(s) is/are constituted by aluminium.
- 19. (currently amended): Method according to any one of claims 1 to 18claim 1, characterised in that the mineral film is constituted by a metal oxide or a mixture of metal oxides.
- 20. (original): Method according to claim 19, characterised in that the metal oxide(s) is/are selected from the oxides of austenitic stainless steel, chromium, titanium, silicon, zinc, tin.
- 21. (currently amended): Method according to any one of claims 1 to 20claim 1, characterised in that the metal material is in the form of a moving strip, and in that the various method steps are carried out continuously by means of installations which are arranged successively over the path of the moving strip.
- 22. (original): Device for coating a metal material in the form of a strip, characterised in that it comprises means for moving the strip and, arranged successively over the path of the strip:

- first means for coating the strip with a layer of a metal or a metal alloy having a melting point equal to $T_{\rm f}$;
- means for rapidly heating the strip which can bring the surface of the layer to a temperature of between $0.8T_{\rm f}$ and $T_{\rm f}$; and
 - second means for coating the strip with a layer of metal or metal alloy.
- 23. (original): Device according to claim 22, characterised in that it comprises, downstream of the second means for coating the strip with a layer of a metal or a metal alloy, means for coating the strip with a transparent mineral film.
- 24. (original): Metal material, characterised in that it comprises, on at least one of the surfaces thereof, a metal coating having a three-dimensional visual effect, the coating being formed directly on the surface of the material.
- 25. (currently amended): Metal material according to claim 24, characterised in that it is produced using the a method according to any one of claims 1 to 21. which

the material is first coated with a layer of a metal or a metal alloy having a melting point equal to T_f and a thickness less than or equal to $2.5\mu m$,

- the first coating is subjected to thermal processing using a rapid heating means in order to bring the surface of the first coating to a temperature of between $0.8T_{\rm f}$ and $T_{\rm f}$; and
- a second coating is deposited from a metal or a metal alloy having a thickness less than or equal to 1μm.